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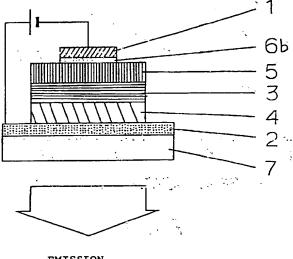
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(54) Organic electroluminescent device

(57) An organic electroluminescent device comprises an anode, a positive-hole transport layer made of an organic compound, an emitting layer made of an organic compound, an electron transport layer made of an organic compound, an electron-injecting layer and a cathode which are layered in sequence. The electron-injecting layer is made of an alkaline metal compound

comprising at least one of Li, Rb, Cs, Na and K including alkaline metal oxides, alkaline metal peroxides, alkaline metal compound oxides, alkaline metal halides, alkaline metal nitride and alkaline metal salt such as Li₂O, Li₂O₂, Rb₂O, Cs₂O, Rb₂O₂, Cs₂O₂, LiAlO₂, LiBO₂, LiCl, RbCl, NaCl, KAlO₂, Na₂WO₄, K₂SiO₃ and Li₂CO₃.





EMISSION

Description

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BACKGROUND OF THE INVENTION

Field of the invention

The present invention relates to an electroluminescent device (hereinafter referred as "EL device") having an emitting layer made of an emitting substance, which utilizes an electroluminescence phenomenon that the emitting substance emits light by applying an electric current to the emitting layer. More particularly, it is concerned with an organic EL device in which the emitting layer is made of an organic emitting substance.

2. Description of the prior art

As a prior art organic EL device structure, there have been known an organic EL device as shown in Fig. 1, in which an electron-injecting layer 6a, an organic electron transport layer 5, an emitting layer 3 and an organic hole transport layer 4 are laminated in sequence and are sandwiched as a whole between a metal cathode 1 and a transparent anode 2 on a glass substrate 7.

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The hole transport layer 4 facilitates the injection of the holes from the arrode and blocks electrons. The electron-injecting layer 6a facilitates the injection of electrons from the cathode. The electron transport layer 5 facilitates the transport of electrons from the electron-injecting layer 6a to the emitting layer 3. In the organic EL device, the recombination of electrons injected from the metal cathode 1 through the electron-injecting layer 6a and the organic electron transport layer 5 and holes injected from the transparent anode 2 to the emitting layer 3 generates excitons. The excitons emit light when they are deactivated through radiation. This light radiates toward outside through the transparent anode 2 and the glass substrate 7.

In addition, there is another organic EL device structure as shown in Fig. 2, in which an electron-injecting layer 6a, an emitting layer 3 and first and second hole transport layers 4a and 4b are laminated in sequence and are sandwiched as a whole between a metal cathode 1 and a transparent anode 2 on a glass substrate 7. The first and second hole transport layers 4a and 4b facilitates the ionization potential levels in a stepwise to promote the injection of positive holes. The voltage to be applied to the EL device with the two hole transport layers is reduced rather than that with the single hole transport layer during the injection of electric current for the light emission.

The anode 2 is formed of an electric conductive material with a high work function such as indium-tin oxide (here-inafter referred as "ITO"). The cathode 1 is formed of a metal with a lower work function such as aluminum (Al), magnesium (Mg), indium (in), silver (Ag) or alloys of the individual metals thereof Al-Mg, Ag-Mg. The electron-injecting layer 6a is provided in order to expand the selection range of materials for the electrode layer. If the cathode 1 is made of a thin metal film with both a lower work function and a low electric resistance, it will be omitted. It is attempted that, for the electron-injecting layer 6a, a material containing at least one of alkaline earth metal oxides such as SrO, CaO or BaO is used in order to expand the selection range of materials for the electrode layer.

However, there is not combination of materials for the electron-injecting layer have a sufficient emission efficiency yet. There is a problem of decrease of luminance in the lapse during a continuous emission.

SUMMARY OF THE INVENTION

The object of the present invention is to provide an organic EL device is capable of continuously emitting at a high luminance:

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The organic EL device according to the present invention comprises; an anode, a positive-hole transport layer made of an organic compound, an emitting layer made of an organic compound, an electron transport layer made of an organic compound and a cathode which are layered in sequence, further comprising an electron-injecting layer containing at least one of alkaline metal compounds and disposed between said emitting layer and said cathode.

In the present invention, the electron-injecting layer disposed between the emitting layer and the cathode layer is made of a compound containing at least one of alkaline metals such as Li, Rb, Cs, Na or K which has a low work function. Therefore, this EL device emits at a high luminance emitting by optimizing the thickness of the electron-injecting layer. The alkaline metal compounds are chemically more stable than a simple substance of alkaline metal and preferably reproduced in the properties thereof. Accordingly, the present invention achieves the organic EL device capable of continuously emitting light for a long time at a high luminance by applied a low voltage.

Other and further features, advantages and benefits of the invention will become apparent in the following description taken in conjunction with the following drawings. It is to be understood that the foregoing general description and following detailed description are exemplary and explanatory but are not to be restrictive of the invention. The accompanying drawings which are incorporated in and constitute a part of this invention and, together with the description,

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serve to explain the principles of the invention in general terms. Like numerals refer to like parts throughout the disclosure.

BRIEF DESCRIPTION OF THE DRAWINGS

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Fig. 1 is a schematic cross section view of an organic EL device;

Fig. 2 is a schematic cross section view of another organic EL device;

Fig. 3 is a schematic cross section view of an embodiment according to the present invention;

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Fig. 4 is a schematic cross section view of another embodiment according to the present invention; and

Fig. 5 shows a graph of luminance decrement property embodiment obtained from an embodiment of the organic embodiment of the organic embodiment of the organic embodiment of the organic embodiment obtained from an embodiment of the organic embodiment of the organic embodiment obtained from an embodiment of the organic embodiment obtained from the organic embodiment obtained from the organic embodiment obtained from the organic embodiment of the organic embodiment

DETAILED DESCRIPTION OF PREFERRED EMBODIMENTS

The embodiments according to the present invention will be described in more detail with reference to the accompanying drawings.

As shown in Fig. 3, the EL device in accordance with the present invention has an electron-injecting layer 6b, an accordance with the present invention has an electron-injecting layer 6b, and accordance electron transport layer 5, an emitting layer 8 and an organic hole transport layer 4 are laminated in sequence and are sandwiched as a whole between a metal cathode stand a transparent anode 2 on a glass substrate 7.48 (1994) and 1994 are 1994 are 1994 and 1994 are 1994 are 1994 are 1994 are 1994 and 1994 are 1994 are 1994 and 1994 are 1

The electron-injecting layer 6b is made of an alkaline metal-compound comprising at least one of Li, Rb, Cs, Na and K including alkaline metal oxides, alkaline metal peroxides, alkaline metal compound oxides, alkaline metal-halides, at a alkaline metal nitride and alkaline metal-salt-such as Li₂O₂ Li₂O₂, Rb₂O, Cs₂O, Rb₂O₂, Cs₂O₂, LiAlO₂, LiBO₂: LiCl₃, alkaline metal nitride and alkaline metal-salt-such as Li₂O₃ Li₂O₂, Rb₂O, Cs₂O, Rb₂O₂, Cs₂O₂, LiAlO₂, LiBO₂: LiBO₂: LiCl₃, alkaline metal-halides, at a likeline metal salt-such as Li₂O₃. Although the electron-injecting layer 6b having a very low work-function acts as an insulator, this EL device emits at a high luminance emitting by optimizing the thickness of the electron-injecting layer. Since the alkaline metal compounds are chemically stable, the treatment thereof is easy. It is therefore the property of the EL device. Accordingly, the present invention achieves a constant production of the organic EL device capable of emitting light for a long time.

The thickness of the electron-injecting layer 6b is required at one angstrom or more on the average. The emission of the EL device is due to the recombination of electrons and holes in the emitting layer as mentioned above almother of electrons and holes in the emitting layer as mentioned above almother of electrons, such an emission relies on electric current across the electrodes. Since the electron-injecting layer is an insulative of the contract of the electron obstructing electric current in the device.

The anode 2 is formed of an electric conductive material with a high-work function such as ITO, tin oxides. The cath-lode 1 is formed of a metal with a lower work function such as Al, Mg, In, Ag or alloys of the individual metals. The anode 2 may be formed of a metal or substance with a higher work function than that of the cathode 1. In these cases, at least one of the electrodes 1 and 2 may be transparent. The both electrodes may be made of transparent conductive materials.

The emitting layer 3 is formed of a fluorescent material preferably, a fluorescent dye with a high quantum yield such as tris(8-hydroxyquinolinol)aluminum (hereinafter referred as "Alq₃") or an aluminum oxine complex.

The emitting layer 3 may be made of both an organic host substance having a capability of transporting a carrier and an organic guest substance having a capability of emitting light in response to either the recombination of electron and positive-hole or the energy transferred from the host substance. This is so-called a guest-host type emitting layer. An example of the host substance is Alq₃, for this cumarin derivatives, dicyanomethlene derivatives or quinacridone derivatives are preferably used as guest substances in the emitting layer. The host substance having the absolute values of oxidation and reduction potential being comparatively large in the cyclic voltammetry (CV) is used for the host substance of the emitting layer 3. A substance having the absolute values of oxidation and reduction potential being comparatively small in the CV is preferably used for the guest substance of the emitting layer 3. The more the overlapped portion of the spectral distributions of both the wavelengths stimulated from absorption wavelengths of the guest substance and fluorescent wavelengths of the host substance, the higher the emitting efficiency becomes in the EL device. The guest substance is preferably selected from fluorescent dyes with a high quantum yield. The guest substance is contained at a concentration 0.01 wt.% through 10 wt.%1 in the fluorescent emitting layer comprising the host material, because the emission with a high luminance of the EL device can be obtained at a low applied voltage.

The organic hole transport layer 4 is formed of a compound of a so-called CTM (Carrier Transporting Materials) capable of transporting holes as a mixture thereof or a lamination thereof. It is preferable that the hole transport layer is made of N, N'-diphenyl-N-N'-bis(3-methylphenyl)-1,1'-biphenyl-4,4'-diamine (hereinafter referred as "TPD"), Copper phthalocyanine, or 4, 4', 4" -tris[N-(3-methylphenyl)-N-phenylamino] triphenylamine (hereinafter referred as "MTDATA").

The electron transport layer 5 is formed of a compound capable of transporting electrons as a mixture thereof or a lamination thereof. It is preferable that the electron transport layer 5 is preferably made of so-called Bu-PBD which is 2-(4'-tert-butylphenyl)-5-(biphenyl)-1,3,4-oxadiazole, Alq₃ or perylene derivatives.

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In addition, another embodiment according to the invention is shown in Fig. 4, in which an electron-injecting layer 6b, an emitting layer 3 and first and second hole transport layers 4a and 4b are laminated in sequence and are sandwiched as a whole between a metal cathode 1 and a transparent anode 2 on a glass substrate 7.

The inventor manufactured concretely organic EL devices each having the structure as shown in Fig. 4 under conditions of the deposition rates and the corresponding thin film making methods as shown in Table 1. Each manufactured EL device was constructed so that a first hole transport layer 4a, a second hole transport layers 4b, an emitting layer 3, an electron-injecting layer 6b and a metal cathode 1 were laminated in sequence on stripe ITO transparent anodes 2 previously formed on the surface of a glass substrate 7.

Table:1

No.: Function -layer	Deposition rate (Angstroms/sec.)	Thin-film -deposition	Thickness (Angstroms)
4a: MTDATA	2-4	Resistance heating	300
4b: TPD	2-4	Resistance heating	300
3: Ala ₃	2-4	Resistance heating	550
6b: Li₂O	⊧ 1-2	Electron beam or Resistance heating	1, 4, 8, 12, and 22
1: Ai	7-14	Resistance heating	1500

In addition, a comparative EL devices were manufactured under the same conditions as the above embodiments excepting the electron-injecting layer was excluded from between the emitting layer and the cathode, i.e., the electron-injecting layer is at zero angstroms. Other comparative EL devices were manufactured under the same conditions as the above embodiments excepting the electron-injecting layers were made of SrO at thickness of 1, 5 and 10 angstroms respectively.

The first hole transport layer 4a made of MTDATA have a high heat-resistant properties of high melting points and a high glass transition points and a high electric conductivity. Since the MTDATA layer is hardly crystallized for a long time and have excellent shielding properties against a surface of another substance, it contributes a high performance organic EL device in the embodiments in which the elevation of temperature of the device is suppressed during the application of a driving current and further the quantum efficiency of the device is increased.

Table 2 shows luminance-emitting efficiency properties of five embodiments having the electron-injecting layers of Li₂O with 1, 4, 8, 12 and 22 thickness respectively and the first comparative Ei. device at luminance 300 cd/m².

Table 2

	Li ₂ O thickness (Angstroms)	Emitting efficiency (Im/W)			
Comparative 1	0	0.49			
Embodiment 1	1				
Embodiment 2	4	1.86			
Embodiment 3	8	2.95			
Embodiment 4	12	2.88			
Embodiment 5	22	2.32			

Table 3 shows luminance-emitting efficiency of other comparative EL devices having the electron-injecting layers of SrO at luminance 300 cd/m².

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Table 3

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1 de 2 de	SrO thickness (Angstroms)	Emitting efficiency (lm/W)
Comparative 2	. 0	0.49
Comparative 3	1	0.94
Comparative 4	5	1.90
Comparative 5	10	1.40

Fig. 5 shows luminance decrement properties resulting from the running of emission tests of the above embodiments and comparatives of the organic EL devices. The graph shows luminance ratio [lapse luminance (L) / initial luminance (L0)] at the coordinate and the lapse of time [hours] at the logarithmic abscissa.

As seen from the result, embodiments with the interposition of Li₂O electron-injecting layers at range 1 - 22 angstroms were remarkably improved in the emitting property and the life time in comparison with the comparative EL devices with SrO electron-injecting layer and excluding the Li₂O electron-injecting layer. Particularly, the EL device comprising the Li₂O electron-injecting layer with 8 angstroms was excellent in Table 2. The embodiments of the EL devices comprising the Li₂O electron-injecting layer with at the thickness range 1 - 30 angstroms were preferable because they have high emitting efficiencies more than about 1.0 (lm/W) at luminance 300 cd/m² as seen from Table 2.

Furthermore, other embodiments of EL devices were manufactured under the same conditions as the above and a second transfer of the conditions of the conditions of the conditions of the conditions are the conditions of the condit embodiments excepting the electron-injecting layers were made of Li₂O₂; LiAlO₂, LiBO₂, LiCl, Cs₂O, NaCl, Na₂WO₄, And the electron-injecting layers were made of Li₂O₂; LiAlO₂, LiBO₂, LiCl, Cs₂O, NaCl, Na₂WO₄, And the electron-injecting layers were made of Li₂O₂; LiAlO₂, LiBO₂, LiCl, Cs₂O, NaCl, Na₂WO₄, And the electron-injecting layers were made of Li₂O₂; LiAlO₂, LiBO₂, LiCl, Cs₂O, NaCl, Na₂WO₄, And the electron-injecting layers were made of Li₂O₂; LiAlO₂, LiBO₂, LiCl, Cs₂O, NaCl, Na₂WO₄, And the electron-injecting layers were made of Li₂O₂; LiAlO₂, LiBO₂, LiCl, Cs₂O, NaCl, Na₂WO₄, And the electron-injecting layers were made of Li₂O₂; LiAlO₂, LiBO₂, LiCl, Cs₂O, NaCl, Na₂WO₄, And the electron-injecting layers were made of Li₂O₂; LiAlO₂, LiBO₂, LiCl, Cs₂O, NaCl, Na₂WO₄, And the electron-injecting layers were made of Li₂O₂; LiAlO₂, LiBO₂, LiCl, Cs₂O, NaCl, Na₂WO₄, And the electron-injecting layers were made of Li₂O₂; LiAlO₂, LiBO₂, LiCl, Cs₂O, NaCl, Na₂WO₄, And the electron-injecting layers were made of Li₂O₂; LiAlO₂, LiBO₂, LiCl, Cs₂O, NaCl, Na₂WO₄, And the electron-injecting layers were made of Li₂O₂; LiAlO₂, LiBO₂, LiCl, Cs₂O, NaCl, Na₂WO₄, And the electron-injecting layers were made of Li₂O₂; LiAlO₂, LiBO₂, LiCl, Cs₂O, NaCl, Na₂WO₄, And the electron-injecting layers were made of Li₂O₂; LiAlO₂, LiBO₂, LiCl, Cs₂O, NaCl, Na₂WO₄, And the electron-injecting layers were made of Li₂O₂; LiAlO₂, LiBO₂, LiCl, Cs₂O, NaCl, Na₂WO₄, And the electron-injecting layers were made of Li₂O₂; LiAlO₂, LiBO₂, LiCl, Cs₂O, NaCl, Na₂WO₄, And the electron-injecting layers were made of Li₂O₂; LiCl, Cs₂O, NaCl, Na₂Cl, NaCl, Na₂Cl, NaCl, Na₂Cl, NaCl, Na₂Cl, NaCl, Na₂Cl, NaCl, NaCl, Na₂Cl, NaCl, Na KAIO₂, K₂SiO₃, RbCl, and Li₂CO₃ at thickness of 10, 20, 30, 40, 50, 60, 80 and 100 angstroms respectively.

Tables 4 and 5 show luminance-emitting efficiency properties of these embodiments having the alkaline a metal- acoustics compound-electron-injecting layers with the above thickness respectively at luminance 300 cd/m². The grant countries of progressing the countries of the c

yten D ™ :	Thickness (Angstroms)		Emit	ting efficie		∕ W) '		A Section of the sect
MA TO THE REST		Alkalin	e-metal-c	ompound	electro	n-injecting	layer	de la little de la Maria d La maria de la
		Li ₂ O ₂	LiAlO ₂	LiBO ₂	LiCI	Cs ₂ O	NaCl	,
	10	1.15	1.45	1.84	2.70	1.28	2.00	
	20	1.48	1.89	1.95	2.86	1.88	2.14	
	30	1.88	1:83	2.62	2.51	2.34	2.30	
	40	1.90	2.44	2.53	3.00	2.70	2.52	
	50	1.93	2.39	2.43	-	2.92	·2.63·	2
	60	1.52	2.58	2.47		2.82	2.60	
	80	1.79	2.29	2.60	2.86	3.C0 -	2.53	
	100	1.33	2.60	2.77	-	3.00	2.52	

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Thickness (Angstroms)	Emitting efficiency (lm/W)						
	Alkaline-metal-compound-electron-injecting layer						
	Na ₂ WO ₄	KAIO ₂	K ₂ SiO ₃	RbC1	Li ₂ CO ₃		
10	2.77	2.85	2.32	1.42	2.97		
20	2.84	2.87	2.72	1.82	1.78		
30	2.87	3.06	2.55	2.03	1.70		
40	2.68	2.98	2.14	2.16	1.23		
50	-	-	-	-	-		
60	-	2.82	2.82	2.73	-		
80	-	2.56	2.56	2.75	-		
100	-	2.03	2.03	2.90	-		

As seen from the result, there are confirmed the improvement of these embodiments with the interposition of the alkaline -metal-compound-electron-injecting layer. The embodiments of the EL devices comprising the alkaline -metal-compound-electron-injecting layer with at the thickness range 1 - 10 angstroms preferably have a high emitting efficiencies more than about 1.0 (lm/W) at luminance 300 cd/m² as seen from Tables 4 and 5.

As described above, the organic EL device according to the present invention comprises the anode, the organic hole transport layer, the organic emitting layer, the organic electron transport layer and the cathode which are laminated in sequence in characterized in that the device further comprises the alkaline -metal-compound-electron-injecting layer inserted between the organic electron transport layer and the cathode. Thus, it is possible according to the present invention to improve the emitting efficiency of the organic EL device which stably emits light at a high luminance and a high luminance upon application of a low voltage for a long time. Moreover, the selection scope of cathode materials is expanded because of possibility free from the restriction of low work function for the cathode layer according to the invention. Furthermore, these preferable properties of the EL device is repeatedly reproduced in the manufacturing process thereof.

It should thus be apparent that the scope of the teaching of this invention is not intended to be limited by only the embodiments that have been expressly disclosed and illustrated, but that instead the scope of the teaching of this invention should be read as being commensurate with the scope of the claims that follow.

40 Claims

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- An organic electroluminescent device comprising an anode made of a conductive material, a positive-hole transport layer made of an organic compound, an emitting layer made of an organic compound, and cathode made of a conductive material which are layered in sequence, further comprising an electron-injecting layer containing at least one of alkaline metal compounds and disposed between said emitting layer and said cathode.
- An organic electroluminescent device according to claim 1, wherein the alkaline metal compound contained in the
 electron-injecting layer is selected from a group consisting of alkaline metal oxides, alkaline metal peroxides, alkaline metal compound oxides, alkaline metal halides, alkaline metal nitride and alkaline metal salt.
- An organic electroluminescent device according to claim 1, wherein the alkaline metal compound contained in the electron-injecting layer is a lithium compound.
- 4. An organic electroluminescent device according to claim 1, wherein the alkaline metal compound contained in the electron-injecting layer is a sodium compound.
 - An organic electroluminescent device according to claim 1, wherein the alkaline metal compound contained in the electron-injecting layer is a potassium compound.

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- 6. An organic electroluminescent device according to claim 1, wherein the alkaline metal compound contained in the electron-injecting layer is a rubidium compound.
- 7. An organic electroluminescent device according to claim 1, wherein the alkaline metal compound contained in the electron-injecting layer is a cesium compound.
- An organic electroluminescent device according to claim 1, wherein said electron-injecting layer have a thickness of 1 - 200 angstroms on an average.

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FIG.1

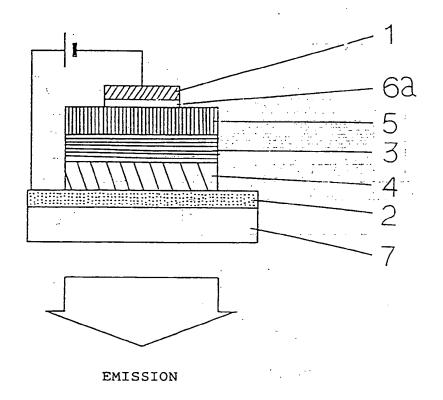


FIG.2

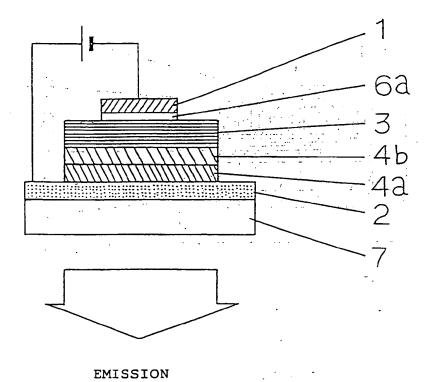


FIG.3

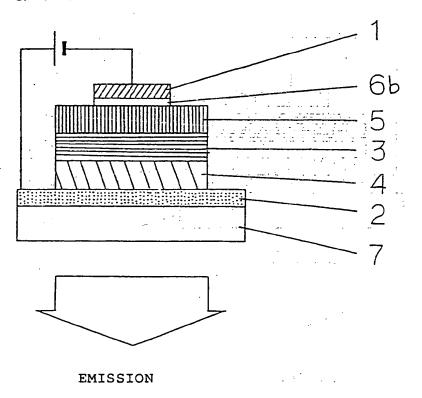
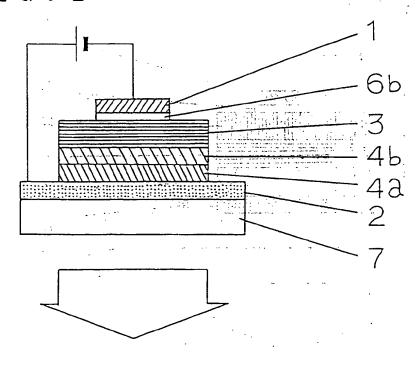
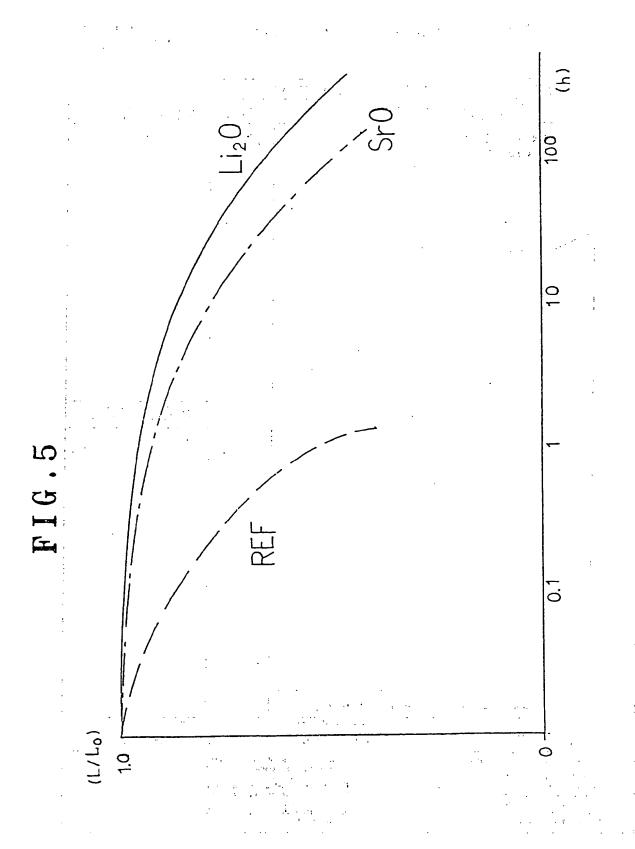


FIG.4



EMISSION





EUROPEAN SEARCH REPORT

Application Number EP 96 10 6373

tegory	Citation of document with indication of relevant passages	, where appropriate,	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int.CL6)
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